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| Applicant(s) | : Hiroomi TSUTAE |) | |
| Appln. No. | : To Be Assigned |)). | INFORMATION |
| Filed - | : September 9, 2003 |) | INFORMATION DISCLOSURE |
| For | : PROCESS OF CLEANING A SEMICONDU MANUFACTURING SYSTEM AND METHO OF MANUFACTURING A SEMICONDUCT DEVICE | OD) | STATEMENT |
| Atty. Dkt. | : FUЛ 136 | ·)_ | |
| Commissione Washington, I | | | |

This is an information disclosure statement submitted in compliance with the timing requirements of 37 C.F.R. §1.97(b)(1).

Attached are copies of three Japanese patent publications. The relevance of the publications can be gleaned from the attached English-language Abstract, and from pages 2 and 3 of the specification, where these documents are discussed. The publications are listed on the attached Form PTO-1449.

Since this Information Disclosure Statement is being filed with the application, no certification or fee is required, and the requirements of 37 C.F.R. §§1.97 and 1.98 are deemed to be fully met as to the document submitted. Consideration of the submitted document is respectfully requested.

Respectfully submitted,

September 9, 2003
Date

Sir:

te Steven M. Rabin (Reg. No. 29,102)

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| FORM PTO-1449 INFORMATION DISCLOSURE STATEMENT | | | ATEMENT | Atty Docket FUJI 136 | Application No. To Be Assigned | | | | | |
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| | | | | Applicant Hiroomi TSUTAE | | | | | | |
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| | | | | September 9, 2003 | To Be Assigned | | | | | |
| U.S. PATENT DOCUMENTS | | | | | | | | | | |
| Examiner Initial | | Document Number | Date | Name | Class | Sub- Class | Filing Date | | | |
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| FOREIGN PATENT DOCUMENTS | | | | | | | | | | |
| | | Document Number | Date . | Country | Class | Sub- Class | Trans- lation | | | |
| | AL | 07-201738 | 08/04/95 | Japan | | | Abstract | | | |
| | AM | 09-249976 | 09/22/97 | Japan | | | Abstract | | | |
| · | AN | 10-147877 | 06/02/98 | Japan | | | Abstract | | | |
| | AO | | | | | | | | | |
| | OTHER (Including Author, Title, Date, Pertinent Pages, etc.) | | | | | | | | | |
| | AP | | | | | | | | | |
| Examiner | | | | | Date Cor | nsidered | | | | |
| EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant. | | | | | | | | | | |